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# LETTERS

## Ultrafast Reaction between LiH and NH<sub>3</sub> during H<sub>2</sub> Storage in Li<sub>3</sub>N

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Li<sub>3</sub>N is a potential H<sub>2</sub> storage material due to its high theoretical H<sub>2</sub> capacity (10.4 wt %). A critical potential issue regarding this N-based storage material is the generation of NH<sub>3</sub>, which consumes some H<sub>2</sub> and also constitutes a poison for the downstream processes. In this Letter, by using the temperature-programmed decomposition of a two-layer material (LiNH<sub>2</sub> and LiH), we demonstrate that NH<sub>3</sub> produced via the decomposition of LiNH<sub>2</sub> is completely captured by LiH even at very short contact times (25 ms) with the carrier gas. This ultrafast reaction between NH<sub>3</sub> and LiH inhibits NH<sub>3</sub> formation during the hydrogenation of Li<sub>3</sub>N and also prevents the NH<sub>3</sub> generated during the dehydrogenation of the hydrogenated Li<sub>3</sub>N to escape into the H<sub>2</sub> stream. However, if the hydrogenated Li<sub>3</sub>N was previously exposed to the atmosphere, some NH<sub>3</sub> could escape into the H<sub>2</sub> stream during the H<sub>2</sub> desorption, due to the partial oxidation of LiH by the water present in air.

#### Introduction

Hydrogen is a promising clean fuel for vehicles, which can use hydrogen for propulsion either directly, or through fuel cells. In both cases, a suitable hydrogen-storage material is needed to make this source of energy economically viable. There are economical issues with the traditional H<sub>2</sub> storage methods, such as the liquefaction process, because the compression and cooling of the hydrogen to 20 K consumes almost 30% of the hydrogen energy.<sup>1</sup> The H<sub>2</sub> adsorption on activated carbon, which has a very high surface area (1500-2000 m<sup>2</sup>/g), also requires a low temperature (77 K) and a high pressure ( $\sim$ 50 atm).<sup>1</sup> Low H<sub>2</sub> storage capacities and slow desorption kinetics are the drawbacks of the metal hydrides. In recent years, the high, reversible adsorption of H<sub>2</sub> onto carbon nanotubes<sup>2-4</sup> has stimulated both experimental and theoretical work for H<sub>2</sub> storage in carbon nanomaterials.<sup>2–11</sup> However, it is still unclear how high hydrogen-storage capability can be reached by these nanostructured carbon materials.<sup>5,6</sup>

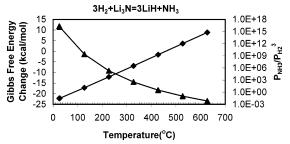
As early as 1910, Dafert and Miklauz<sup>12</sup> reported that the reaction between  $Li_3N$  and  $H_2$  generated  $Li_3NH_4$  (a mixture of 2LiH and  $LiNH_2^{13}$ )

$$Li_3N + 2H_2 = Li_3NH_4$$

Consequently,  $Li_3N$  can theoretically store 10.4 wt % hydrogen. Furthermore, they found that  $Li_3NH_4$  can be partially decomposed to release  $H_2$ .<sup>12</sup> Therefore, the hydrogenation of  $Li_3N$  and the dehydrogenation of the hydrogenated  $Li_3N$  constitute a reversible process, which can be used for  $H_2$  storage.<sup>14</sup> Our experiments have shown that the complete recovery of  $Li_3N$ from the hydrogenated compounds is a difficult process that requires high temperatures (above 430 °C) and long times. The use of such high temperatures produces sintering and the recovered  $Li_3N$  becomes ineffective. For this reason, the reversible storage capacity of  $Li_3N$  is about 5 wt %.

However, one critical issue with this N-based material is the possibility of  $NH_3$  generation during the hydrogenation of  $Li_3N$  and during the decomposition of the hydrogenated  $Li_3N$ , because the  $NH_3$  formation from  $H_2$  and  $Li_3N$  is thermodynamically a

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**Figure 1.** Thermodynamics of Li<sub>3</sub>N hydrogenation to NH<sub>3</sub>: ( $\blacklozenge$ ) Gibbs free energy change; ( $\blacktriangle$ )  $P_{NH_3}/P_{H_2}^{-3}$ ).

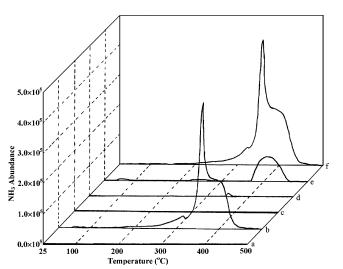
very favorable process at temperatures below 400 °C (see Figure 1). In this paper, by using two-layer materials and short contact times between them and the carrier gas (He), we found that the ultrafast reaction between  $NH_3$  and LiH inhibits the  $NH_3$  generation during the hydrogenation of Li<sub>3</sub>N and prevents  $NH_3$  to escape into the  $H_2$  stream during dehydrogenation.

#### Experiments

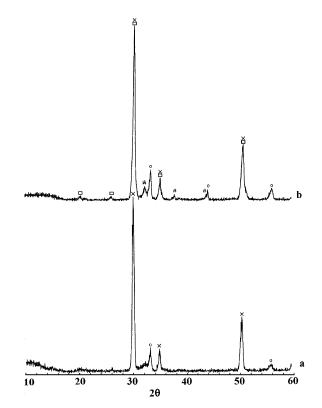
Two types of two-layer materials were used: in one, denoted TLM-1, LiNH<sub>2</sub> was the first layer and LiH the second one; in the other (TLM-2), the order of the layers was inverted. The mole ratio of LiH to LiNH<sub>2</sub> was in both cases equal to 2. The temperature-programmed decomposition mass spectrum (TP-DMS) of these two-layer materials was performed as follows: A carrier gas (He) was allowed to flow at 1 atm pressure through the two-layer material (0.03 g; with an exception of 0.003 g)for the shortest contact time experiment), which was placed in a fixed bed reactor located in an electric furnace, programmed to heat at a rate of 3 °C/min. The gaseous products of the decomposition of the first layer were passed by the carrier (He) through the second layer, and finally, all the gaseous molecules, including those produced in the second layer, were carried into a mass spectrometer (HP Quadrupole, 5971 series mass selective detector) equipped with a fast response inlet capillary system to detect NH<sub>3</sub>. Very high space velocities of the carrier gas were used to achieve very short contact times between the gas molecules and the two-layer materials (as short as 2.4 ms).

#### **Results and Discussion**

During the temperature-programmed decomposition of TLM-1, in which the carrier gas (He) has passed first through the LiNH<sub>2</sub> layer and then through the LiH layer, no NH<sub>3</sub> was detected (Figure 2a). In contrast, for the reverse two-layer material (TLM-2), in which the carrier gas (He) has passed first through the LiH layer and then through the LiNH<sub>2</sub> layer, NH<sub>3</sub> was detected in the broad temperature range between 60 and 500 °C (Figure 2b). This means that NH<sub>3</sub> was formed through the decomposition of LiNH<sub>2</sub> but was captured by LiH. To examine how fast LiH has captured the NH3 formed via the LiNH<sub>2</sub> decomposition, millisecond contact times were employed. For a contact time as short as 25 ms, NH<sub>3</sub> was still completely captured by LiH at all temperatures (Figure 2c). Even when the contact time was as short as 2.4 ms, 99.7% of NH<sub>3</sub> resulted from the LiNH<sub>2</sub> decomposition could be captured. Only 0.3% of the NH<sub>3</sub> resulted from LiNH<sub>2</sub> decomposition passed into the gas-phase stream (Figure 2d). This demonstrates that LiH can capture ultrafast the NH<sub>3</sub> formed during the H<sub>2</sub> release process of the hydrogenated Li<sub>3</sub>N. Furthermore, in practice, the contact times are much longer than 10<sup>3</sup> ms, and hence no NH<sub>3</sub> impurity



**Figure 2.** Temperature-programmed decomposition mass spectra: (a) TLM-1 with a contact time of 110 ms; (b)TLM-2 with a contact time of 110 ms; (c) TLM-1 with a contact time of 25 ms; (d) TLM-1 with a contact time of 2.4 ms; (e) TLM-1 with a contact time of 110 ms (exposed to air for 24 h before the experiment); (f) the two-layer material, with LiNH<sub>2</sub> as the first layer and Li<sub>2</sub>O as the second one.



**Figure 3.** XRD patterns of TLM-1 after the temperature-programmed decomposition: (a) first layer; (b) second layer ( $\times$ ) Li<sub>2</sub>NH; ( $\square$ ) LiNH<sub>2</sub>; (#) LiH; (\*) LiOH; ( $\bigcirc$ ) Li<sub>2</sub>O.

is expected to escape into the  $H_2$  stream when  $Li_3N$  is used as storage material.

XRD was used to examine the phase transformations of the two-layer material (TLM-1) after the decomposition reaction. As shown in Figure 3, LiNH<sub>2</sub> of the first layer has decomposed to Li<sub>2</sub>NH, whereas LiH of the second layer was transformed to Li<sub>2</sub>NH and LiNH<sub>2</sub>. The presence of Li<sub>2</sub>O and LiOH was a result of the exposure of the sample to the atmosphere during the XRD measurements and the reaction of LiH with the water from the

atmosphere. Consequently, the following transformations occurred:

$$2\text{LiNH}_2 \rightarrow \text{Li}_2\text{NH} + \text{NH}_3$$
$$\text{NH}_3 + \text{LiH} \rightarrow \text{LiNH}_2 + \text{H}_2$$

The complete hydrogenation of Li<sub>3</sub>N generated a mixture of 2LiH and LiNH<sub>2</sub> (Li<sub>3</sub>N + 2H<sub>2</sub>  $\rightarrow$  LiNH<sub>2</sub> + 2LiH).<sup>12-14</sup> The generation of a LiNH<sub>2</sub> molecule was accompanied by the formation of two LiH molecules. Because LiH reacts quickly with NH<sub>3</sub>, the LiH generated via the Li<sub>3</sub>N hydrogenation could capture all the NH<sub>3</sub> formed via the LiNH<sub>2</sub> decomposition, and NH<sub>3</sub> could not escape into the H<sub>2</sub> stream during the H<sub>2</sub> release process.

The ultrafast reaction between NH<sub>3</sub> and LiH affected also the product composition and prevented the formation of a NH<sub>3</sub> impurity during the hydrogenation process of Li<sub>3</sub>N. Because Li<sub>2</sub>NH was detected during the hydrogenation of Li<sub>3</sub>N,<sup>14</sup> the hydrogenation of Li<sub>3</sub>N is a multistep process: Li<sub>3</sub>N was first hydrogenated to Li<sub>2</sub>NH and LiH. Further, Li<sub>2</sub>NH was hydrogenated to LiNH<sub>2</sub> and LiH, and LiNH<sub>2</sub> was hydrogenated to LiH and NH<sub>3</sub>. This means that for each NH<sub>3</sub> molecule generated, three LiH molecules were formed. Because the reaction between LiH and NH<sub>3</sub> to LiNH<sub>2</sub> is ultrafast, all NH<sub>3</sub> was transformed to LiNH<sub>2</sub>. Consequently, the products of the complete hydrogenation of Li<sub>3</sub>N are LiNH<sub>2</sub> and LiH. In other words, the ultrafast reaction between NH<sub>3</sub> and LiH also inhibits the NH<sub>3</sub> formation during the hydrogenation of Li<sub>3</sub>N.

However, for a two-layer TLM-1 that was previously exposed to the atmosphere for 24 h, NH<sub>3</sub> was detected during the TPD (Figure 2e). This occurred because TLM-1 absorbed water from the atmosphere, which oxidized LiH to Li<sub>2</sub>O. The Li<sub>2</sub>O formed could no longer capture NH<sub>3</sub>. Indeed, when LiH in TLM-1 was completely replaced by  $Li_2O$ , three NH<sub>3</sub> peaks were identified in the TPD (Figure 2f). This observation indicates that if a hydrogenated  $Li_3N$  was previously exposed to the atmosphere, NH<sub>3</sub> is expected to escape into the H<sub>2</sub> stream during the desorption process. Indeed, NH<sub>3</sub> was detected during H<sub>2</sub> desorption from a hydrogenated  $Li_3N$ , which was previously exposed to the atmosphere for 24 h.

In conclusion, the ultrafast reaction between LiH and  $NH_3$  prevents a  $NH_3$  impurity to escape into the  $H_2$  flow during the entire  $H_2$  storage process. However, if the hydrogenated Li<sub>3</sub>N was previously exposed to the atmosphere, some  $NH_3$  is expected to escape into the  $H_2$  stream during the  $H_2$  desorption, due to the partial oxidation of LiH.

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